



# Lightweight X-ray Optics

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# Metrics of X-ray Optics



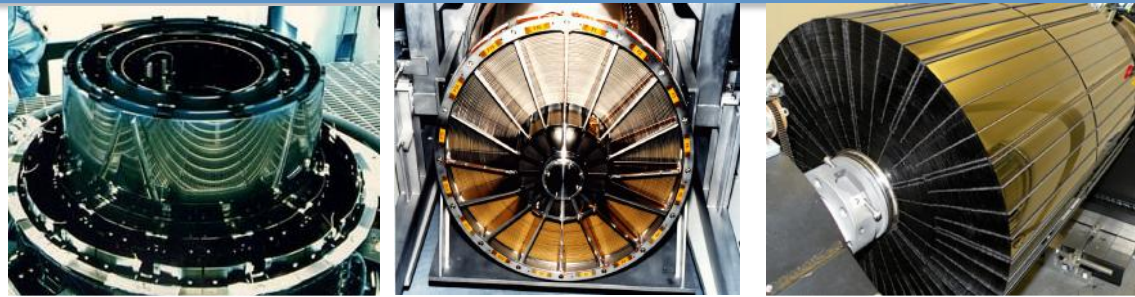
- **PSF:** Angular Resolution
- **Mass** per unit Effective Area
- **Cost** per unit Effective Area

## **Definition of Progress:**

**10 times** better than existing technology in one or more of the three metrics



# Missions in Operations



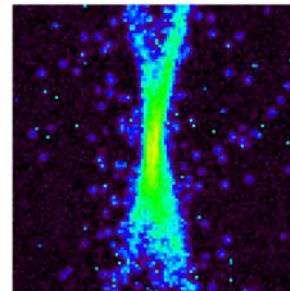
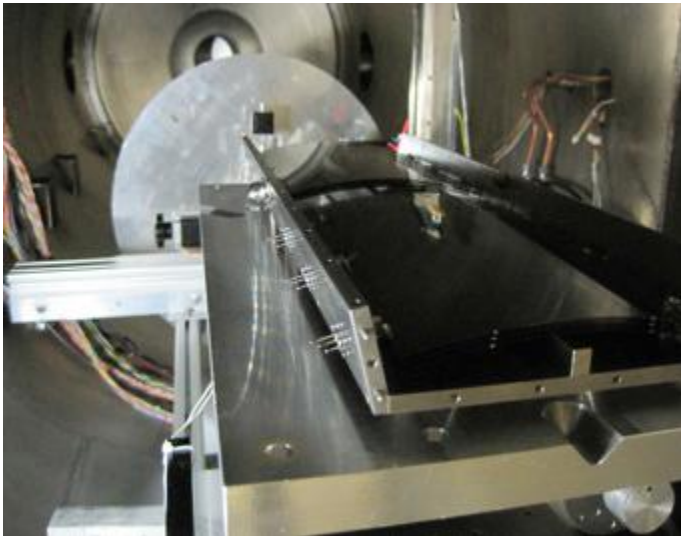
	Chandra	XMM-Newton	NuSTAR
Agency	NASA	ESA	NASA
PSF (" HPD)	0.5	15	58
Mass/EffArea (kg/m <sup>2</sup> )	~18,000	~2,000	~180
Cost/EffArea (\$/m <sup>2</sup> , 2013\$)	~\$10,000M	~\$413M	~\$50M



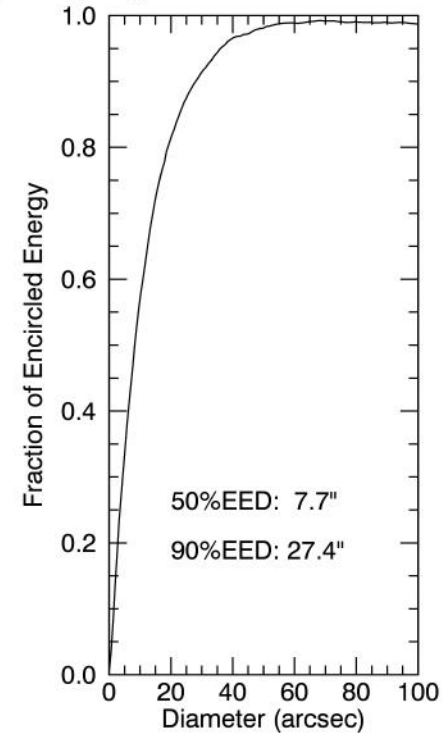
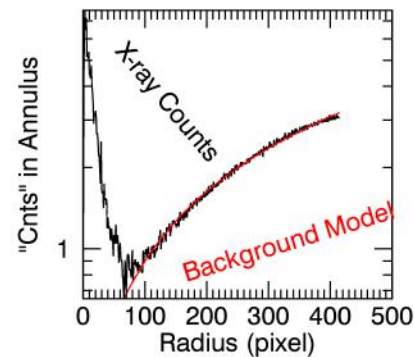
# Technology for IXO



MP23\_140522\_310\_3Pairs\_F-50\_1057.TIF



Centroid=(455, 419)



Based on glass slumping. Mature.  
Ready for missions requiring 10" PSF.



# Future Missions



	PSF (" HPD)	Mirror Area (m <sup>2</sup> )
<b>HST</b>	0.1	5
<b>Chandra</b>	0.5	19
<b>TMT</b>	~0.1	~700
<b>Athena</b>	5	~700
<b>X-ray Surveyor</b>	~0.5	~700
<b>Probes, Explorers</b>	0.1 - 10	20 - 200



# Three Challenges



- **Mirror Fabrication**

Make  $\sim 10^2 \text{ m}^2$  of lightweight optics  
at reasonable **cost** in reasonable **time**

- **Coating**

Coat 15nm of iridium without degrading figure

- **Alignment and Bonding**

Integrate  $\sim 10^4$  mirrors into an assembly  
at reasonable **cost** in reasonable **time**



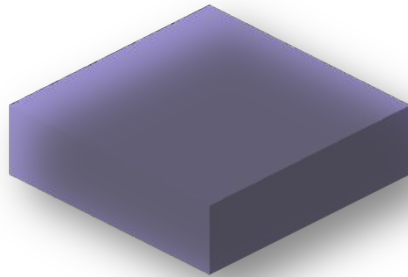
# Mirror Fabrication



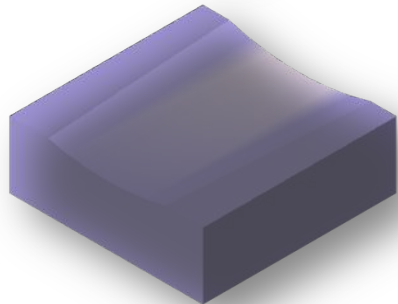
- **Use single crystal silicon**
  - Perfect structure, no internal stress
  - Low density, high thermal conductivity, low CTE, and high stiffness
- **Use “grind & polish”**
  - Proven technique for making high quality optics
- **Develop and perfect**
  - A process to make thin & lightweight mirrors
  - A mass-production process to lower cost and production time



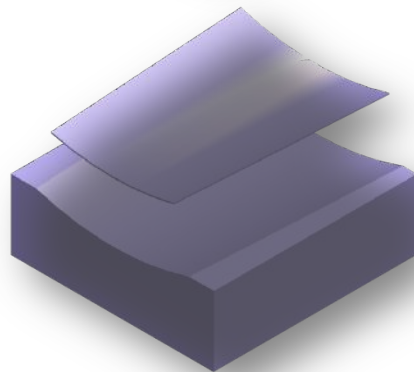
# Mirror Fabrication Concept



Single crystalline silicon:  
Stress free



A high quality mirror, made  
with existing polishing



Light-weighting:  
Slicing and removal of  
damage by acid etch





# Concept Proven

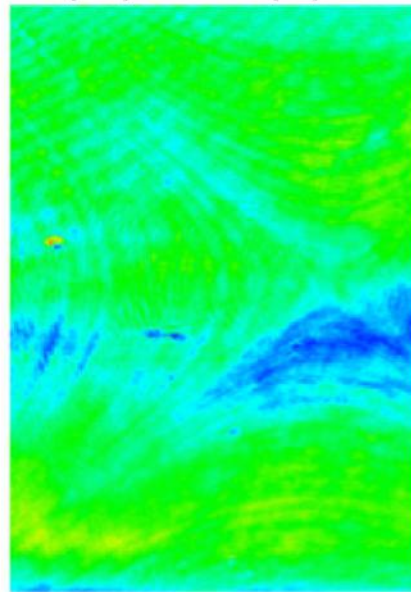


Before Slicing



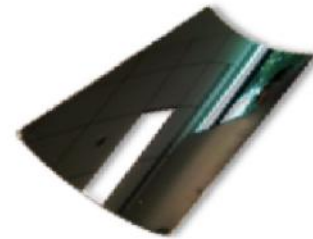
H(nm): 15 S(as): 0.6

Axial Height: 100 mm



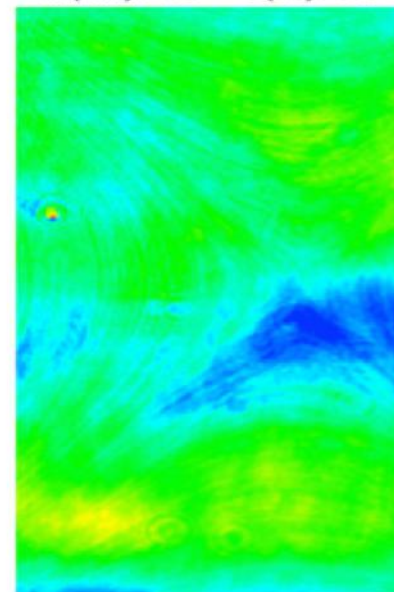
Azimuthal Span: 30 deg

After Slicing & Etching



H(nm): 18 S(as): 0.6

Axial Height: 100 mm



Azimuthal Span: 30 deg



# Coating Concept



- Sputter both sides of silicon mirrors with 15nm of iridium to minimize net stress
- Anneal coated mirrors to eliminate residual net stress



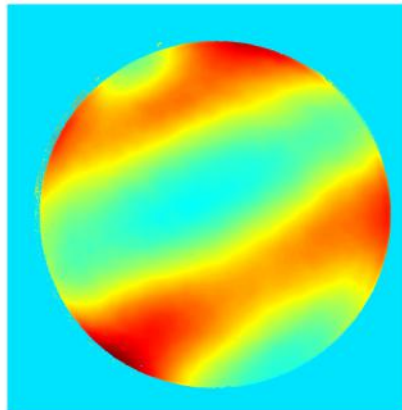
# Coating Concept Proven



Wafer#1

Bare Wafers

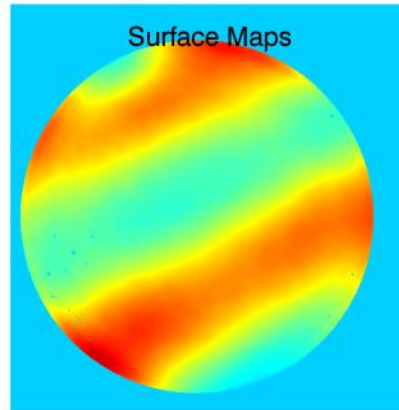
SiWafer-SPSJ01-Front-M01-150713\_1305



Iridium Coated  
on Both Sides

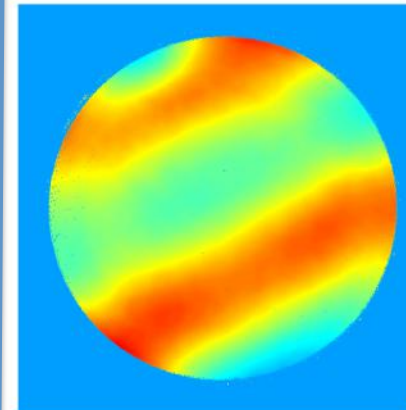
SiWafer-SPSJ01-Front-M05-150901\_1057

Surface Maps



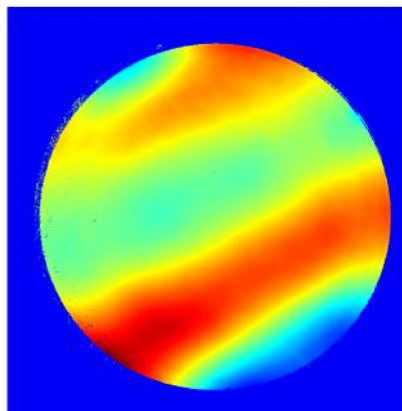
After Annealing

SiWafer-SPSJ01-Front-M06-151019\_1305

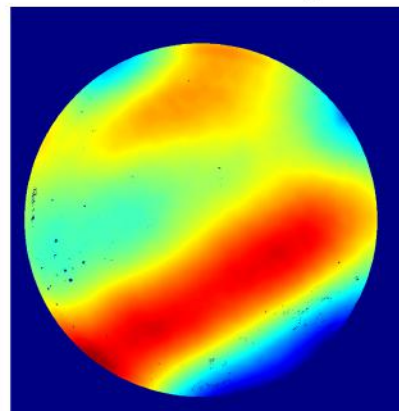


Wafer#2

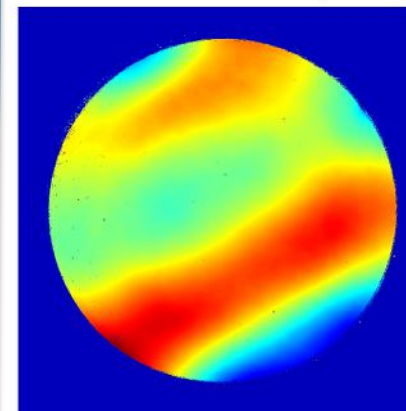
SiWafer-SPSJ02-Front-M01-150713\_1308



SiWafer-SPSJ02-Front-M05-150901\_1020



SiWafer-SPSJ02-Front-M06-151019\_1259

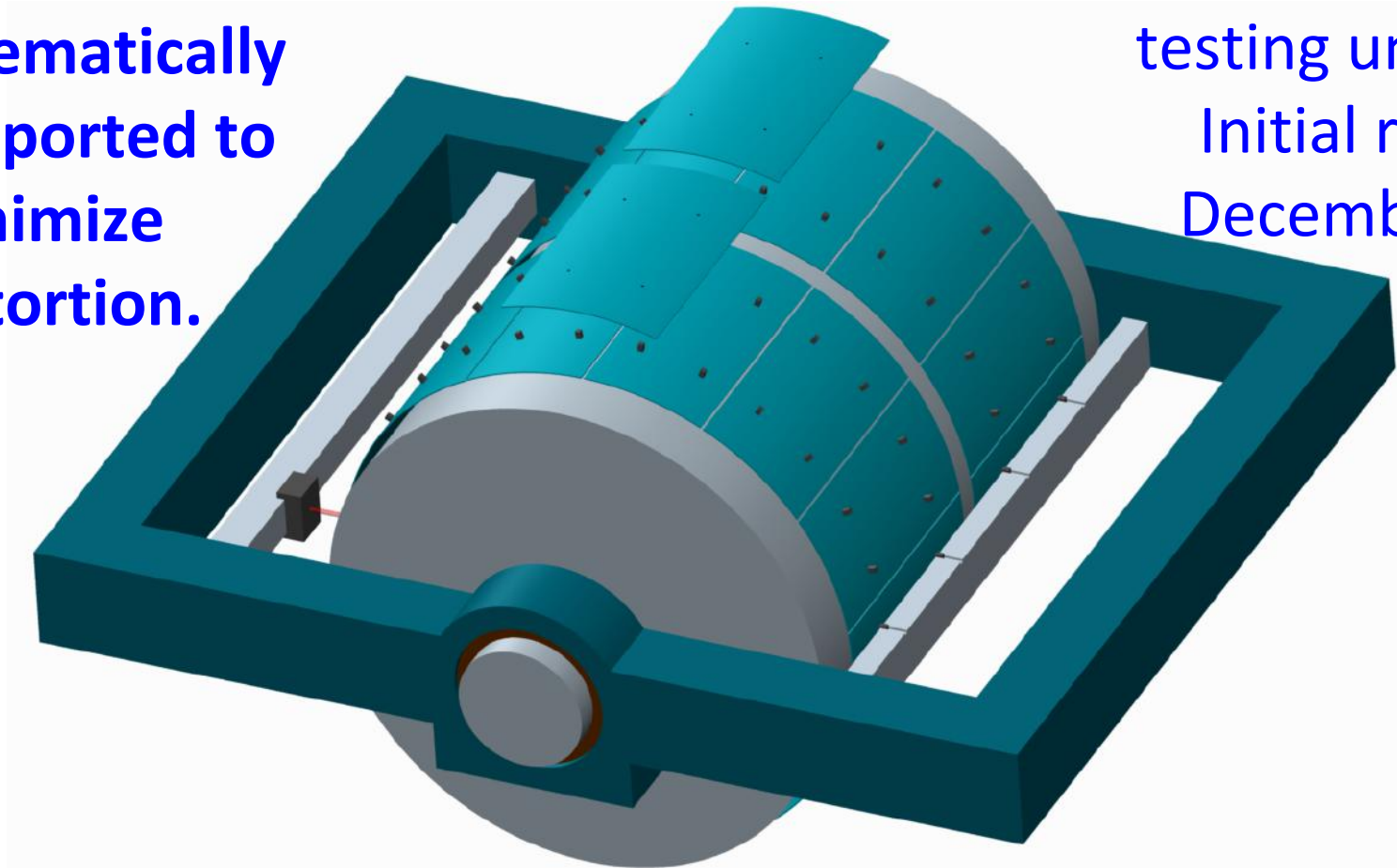




# Alignment and Bonding Concept



Each mirror kinematically supported to minimize distortion.



Implementation and testing underway. Initial results by December 2016.



# Status and Prospects



- **Slumped glass technology ready for making 10" X-ray telescopes**
  - 10 times lighter than XMM-Newton's, comparable angular resolution
  - 10 times better angular resolution than Suzaku's, comparable weight
- **Single crystal silicon mirror technology under development**
  - Mirrors currently at ~2" level
  - Diffraction-limited performance possible (~0.1")
  - Coating, alignment and bonding being worked on
  - ~2" X-ray images expected for December 2016
  - Likely to reach 1" by 2020, ready to support the X-ray Surveyor mission



# Other Development Efforts



- **Efforts to improve the glass slumping process**
  - MPE, Germany ([Winter et al.](#))
  - OAB, Italy ([Gigho et al.](#))
- **Efforts to improve slumped glass mirrors**
  - Differential deposition at [MSFC \(Ramsey et al.\)](#) & [RXO \(Windt\)](#)
  - Piezo adjustable at [SAO & PSU \(Reid et al.\)](#)
  - Magnetic smart material at [Northwestern Univ. \(Ulmer et al.\)](#)
  - Ion implant at [MIT \(Schattenburg et al.\)](#)
- **Efforts to grind and polish thin full shells**
  - OAB, Italy ([Pareschi et al.](#))
  - MSFC ([Gubarev et al.](#))
- **Efforts to improve mirror bonding**
  - Using solder at MIT ([Schattenburg et al.](#))



# Next Generation X-ray Optics Team



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